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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10056342	FILING DATE 01 24 2002	CLASS 438	SUBCLASS 592	GAU 1765	EXAMINER W10
<p>**APPLICANTS: Thomas Terence DeNardi Stephan Godfrey Wade</p>					
<p>**CONTINUING DATA VERIFIED:</p>					
<p>** FOREIGN APPLICATIONS VERIFIED:</p>					
<p>PG PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/> RESCIND <input type="checkbox"/></p>					
<p>Foreign priority claimed <input type="checkbox"/> Yes <input type="checkbox"/> No</p>				<p>ATTORNEY DOCKET NO</p>	
<p>Foreign priority conditions met <input type="checkbox"/> Yes <input type="checkbox"/> No</p>				<p>010025US</p>	
<p>Verified and Acknowledged Examiners initials</p>					
<p>TITLE : Metal polishing slurry having a static etch inhibitor and method of formulation</p>					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
<p>ISSUE FEE</p> <p>Amount Due Date Paid</p>		<p>DRAWING</p> <p>Sheets Drwg. Figs. Drwg. Print Fig.</p>	
<p><input type="checkbox"/> TERMINAL DISCLAIMER</p>		<p>Application Examiner</p>	
<p>PREPARED FOR ISSUE</p>		<p>WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.</p>	

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